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SHEET 1 OF 1

<b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>  (PTO-1449)				ATTY. DOCKET NO. <b>073759-0016</b>		SERIAL NO. <b>10/586,876</b>	
				APPLICANT <b>Yasuhito MASUDA, et al.</b>			
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<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code <sup>2</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
		US					
		US					
		US					
		US					
<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Code <sup>1</sup> -Number 4-Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation Yes      No	
		JP 42-13560	08-01-1967	SUMITOMO ELECTRIC INDUSTRIES, LTD.		JAPAN (w/partial English translation)	
		JP2002-160079	06-04-2002	LASER GIJUTSU SOGO KENKYUSHO; TOYO SEIMITSU KOGYO KK		JAPAN (w/English Abstract)	
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		JP3283265	03-01-2002		Corresponds w/ WO 95/27587		X
<b>OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
		WADA, S., et al., "Direct photoetching of polymer films using vacuum ultraviolet radiation generated by high-order anti-Stokes Raman scattering." , APPL. PHYS. LETTER, January 18, 1993, pages 211-213, vol. 62 No. 3, American Institute of Physics.					
EXAMINER				DATE CONSIDERED			

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<sup>1</sup> Applicant's unique citation designation number (optional). <sup>2</sup> Applicant is to place a check mark here if English language Translation is attached.